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## Correction: Low temperature, rapid and controllable growth of highly crystalline ZnO nanostructures *via* a diluent hydrolytic process and its application to transparent super-wetting films

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Correction for 'Low temperature, rapid and controllable growth of highly crystalline ZnO nanostructures *via* a diluent hydrolytic process and its application to transparent super-wetting films' by Huijie Wang *et al.*, *CrystEngComm*, 2018, 20, 7602–7609.

The formula of HTMS provided in section 2.1 of the published article is incorrect. The correct formula is  $C_{13}F_{17}H_{13}O_3Si$ . The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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